



Oregon

Tina Kotek, Governor

Department of Environmental Quality

Northwest Region

700 NE Multnomah Street, Suite 600

Portland, OR 97232

(503) 229-5696

FAX (503) 229-6124

TTY 711

January 12, 2026

via electronic delivery (email)

Christina Morgon

Intel Corporation

christina.morgon@intel.com

Re: DEQ Request for PFAS Sampling
Intel – Aloha Facility
ECSI #1131

Christina Morgon:

Earlier this year, the Oregon Department of Environmental Quality (DEQ) Cleanup Program requested¹ that Intel Corporation (Intel) voluntarily conduct sampling for per- and polyfluoroalkyl substances (PFAS) at their facility located at 3585 SW 198th Avenue in Aloha, Oregon. Specifically, DEQ requested sampling to confirm that PFAS are not present in the vicinity of a historical waste solvent release in the Fab 5 Building area at the facility. DEQ's request was based on review of publicly available sources indicating that PFAS may be associated with the release². At the time of the request, PFAS were not regulated by DEQ as hazardous substances. While the request for sampling was voluntary, we indicated that a No Further Action (NFA) determination could not be issued until DEQ's concern was addressed, and that DEQ rulemaking was forthcoming.

In September 2025, the following six PFAS were designated as hazardous substances in Oregon as Administrative Order No. DEQ-28-2-25: PFOA, PFOS, PFBS, PFHxS, PFNA, and HFPO-DA (GenX). Information on our rulemaking can be found at: PFAS.2025@deq.oregon.gov

DEQ recognizes and appreciates the cost and effort that went into characterization and cleanup of the solvent release and is reluctant to introduce the PFAS issue. We would be remiss, however, in issuing a NFA without confirmation that these chemicals are not present at levels that might pose a risk to public health or the environment.

Based on the information presented above, DEQ requests that you submit a work plan for reconnaissance-level groundwater sampling in the solvent release area. If PFAS are not detected or present at concentrations below relevant risk-based concentrations, we are prepared to proceed with issuance of a NFA for the solvent release.

¹ DEQ email requesting sampling for PFAS chemicals. Erin McDonnell; July 31, 2025

² Background on Semiconductor Manufacturing and PFAS. Semiconductor PFAS Consortium; May 17, 2023.

Please confirm receipt of this letter and DEQ's request for follow-up. We request that a draft work plan be submitted for DEQ review within 45 days.

Respectfully,

Erin McDonnell, Engineer
Northwest Cleanup and Emergency Response

Ec: Daniel Hafley, DEQ
Kevin Parrett, DEQ
Gary Vrooman, DOJ
ECSI# 1131 File